

Characterization of a NTD Double-Sided Silicon Strip Detector using a Pulsed Ion Beam

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Characterization of a NTD Double-Sided Silicon Strip Detector using a Pulsed Ion Beam

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- ▶ Proceedings for the IEEE Nuclear Science Symposium Conference Records.
- ▶ Presented at Seattle conference, November 2014.

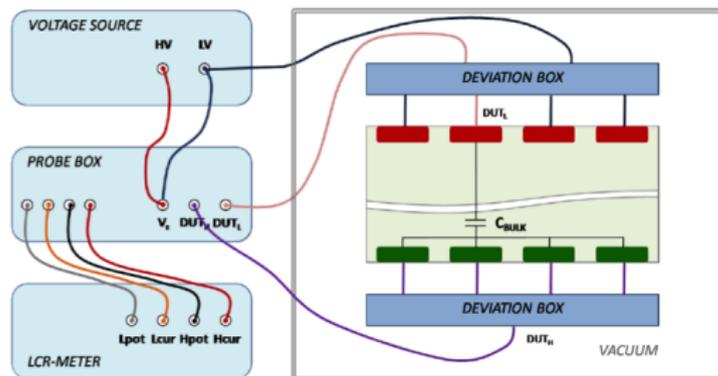


Laboratorio di Tecniche Nucleari per i Beni Culturali

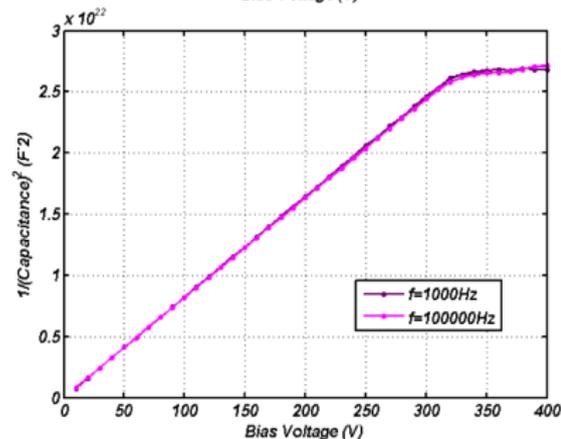
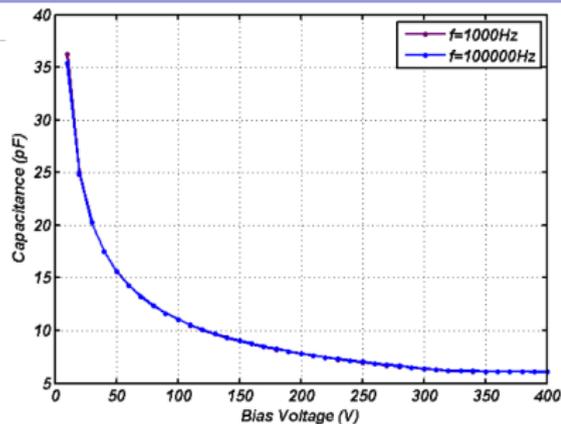
- ▶ DEFEL beamline.
- ▶ Monoenergetic pulsed beam:
 - ▶ **1 & 3 MeV** protons.
 - ▶ 13 MeV carbon.
- ▶ Variable and finely controllable number of particles in each pulse.
- ▶ X-Y stages that can be moved orthogonal to the beam axis.
- ▶ Beam area arriving:
 - ▶ $105\mu\text{m} \times 108\mu\text{m}$, protons.
 - ▶ $205\mu\text{m} \times 208\mu\text{m}$, carbon.



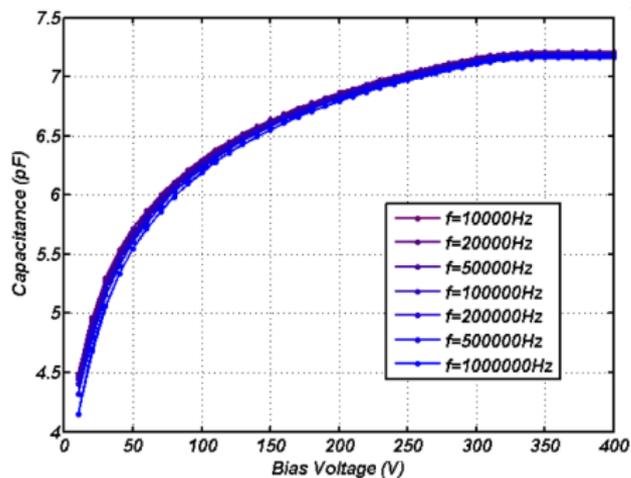
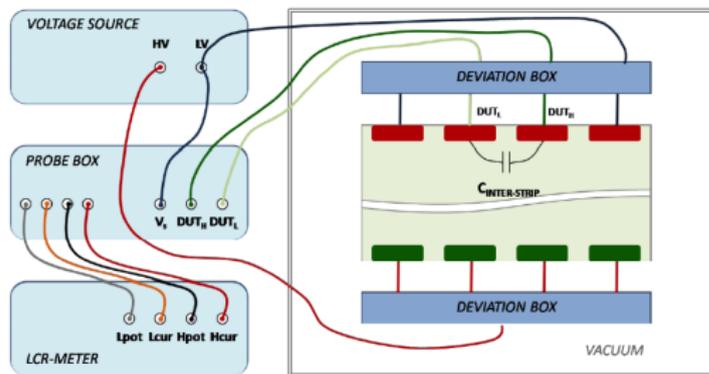
Photo from the web of LaBeC (<http://labec.fi.infn.it>)



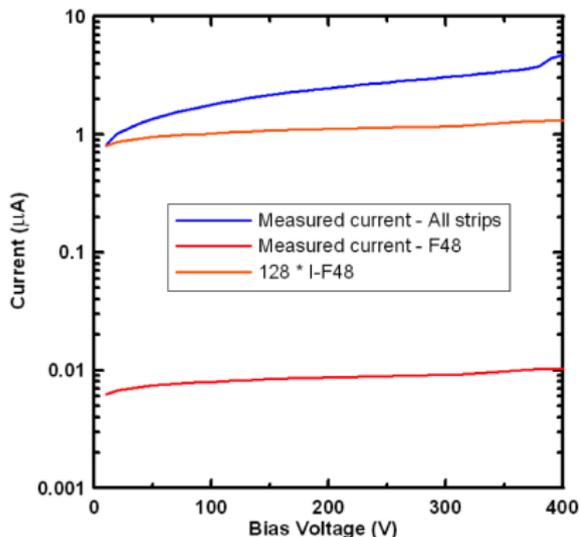
- ▶ Agilent E4980A LCR meter.
- ▶ Frequencies range 1 kHz - 1 MHz.
- ▶ Extracted bulk resistivity 2.3 kΩcm.
- ▶ Full depletion ≥ 350 V.
- ▶ Bulk capacitance 6 pF.



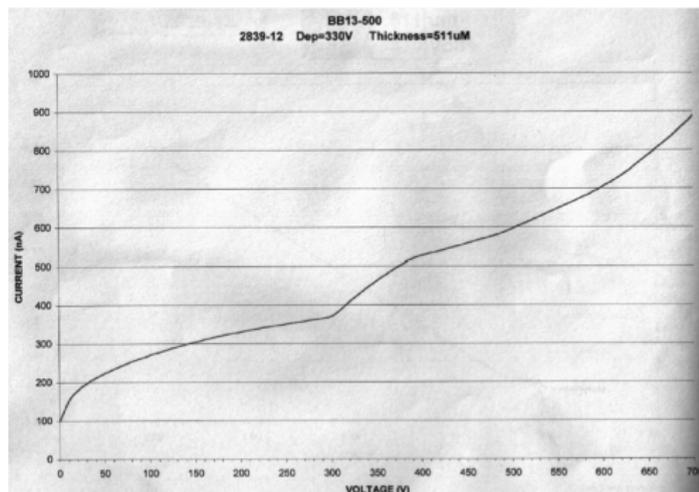
- └ Detector electrical characterisation
- └ INTERSTRIP CAPACITANCE vs BIAS



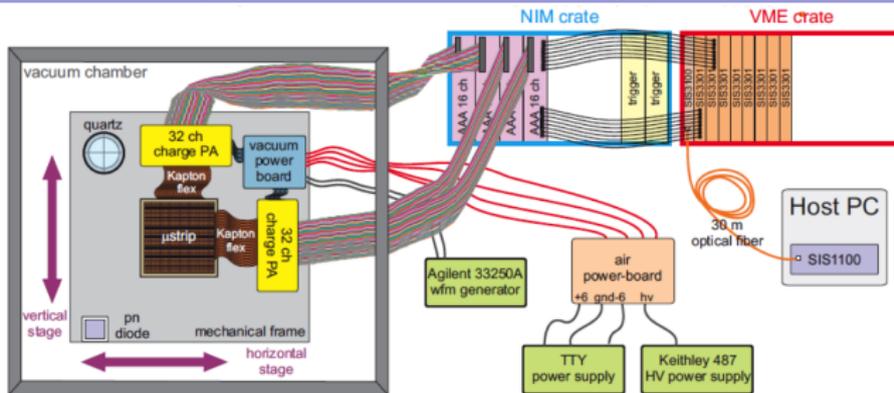
- ▶ Interstrip capacitance.
- ▶ Single-side contribution.
- ▶ On the junction side.
- ▶ 7 pF at full depletion.



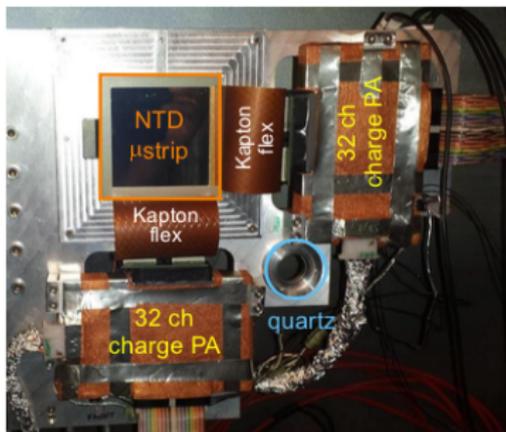
- ▶ Total current, all the strips (blue line).
- ▶ Single strip (F48, a central strip, red line).

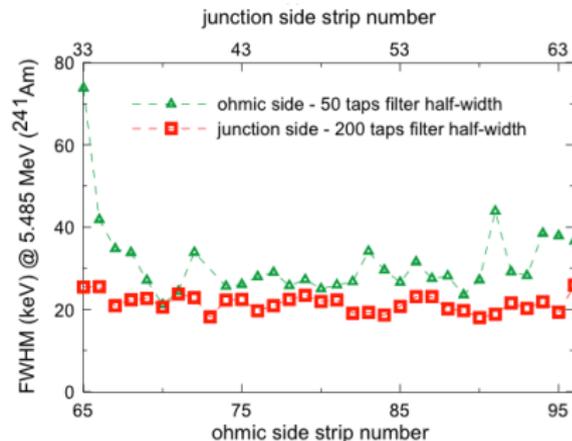
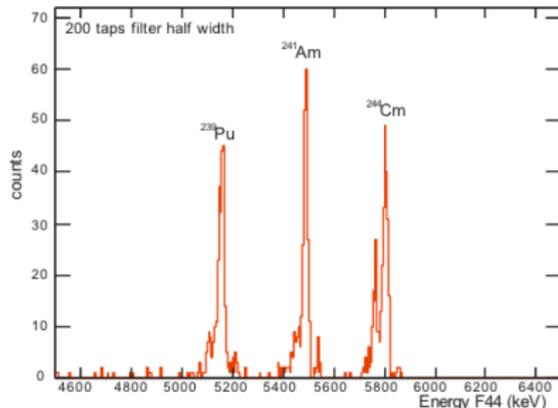


- ▶ Orange, the contribution of 128 of such strip.
- ▶ MicronSemiconductors given IV curve.

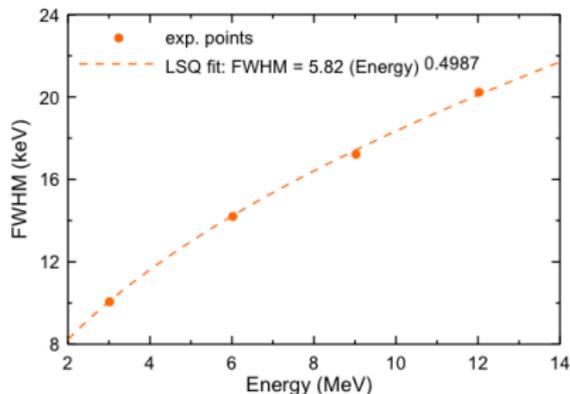
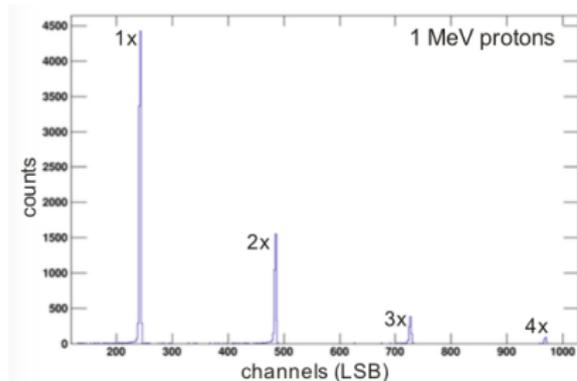


Scheme of principle of the experimental setup. The host PC is located outside the radiation controlled area.





- ▶ Off-line with different digital filters.
- ▶ Triple alpha yielded 20 keV resolution.
- ▶ Best resolution on P-side (junction) rather N-side (ohmic)
- ▶ due to a larger parallel noise, mainly arising from the interstrip resistance.

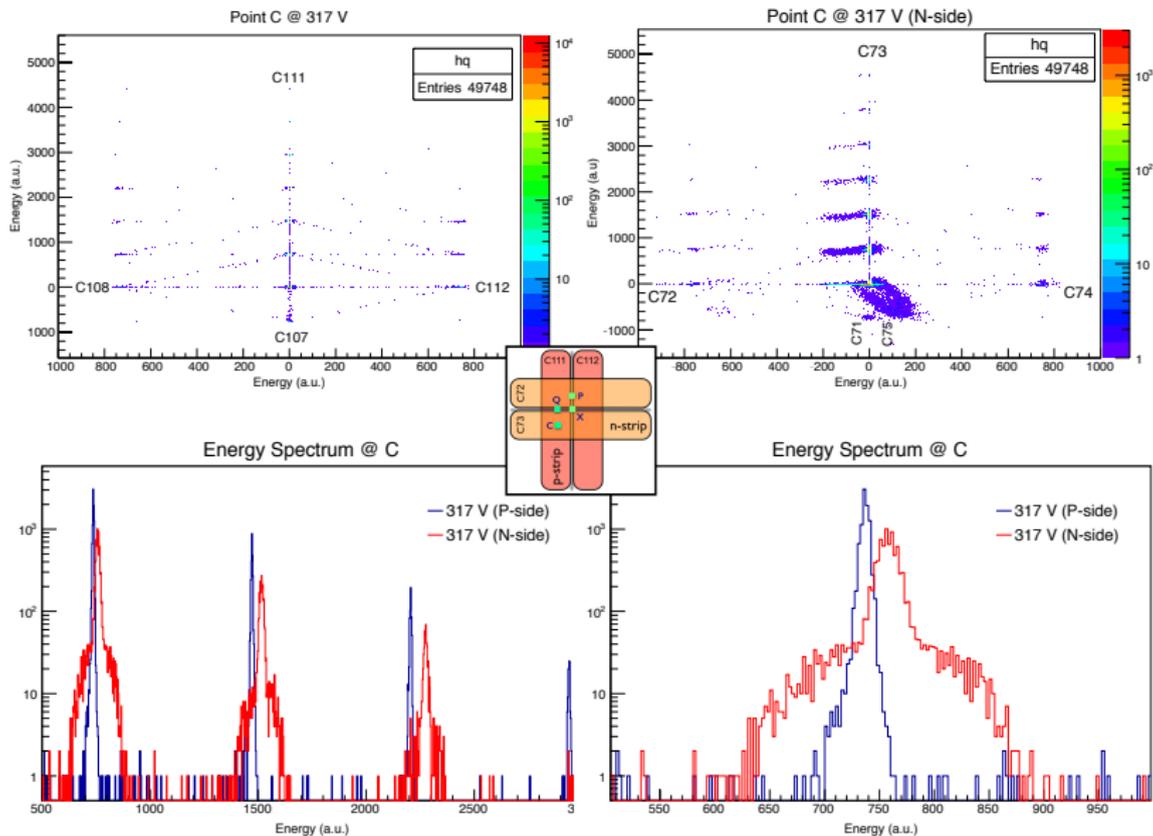


- ▶ Off-line with different digital filters.
- ▶ Different bunch multiplicity (1, 2, 3 and 4 protons per bunch).
- ▶ 10 keV energy resolution at 1 MeV protons.

Test with Microprobe @ LaBeC

└ Results, N-side injection

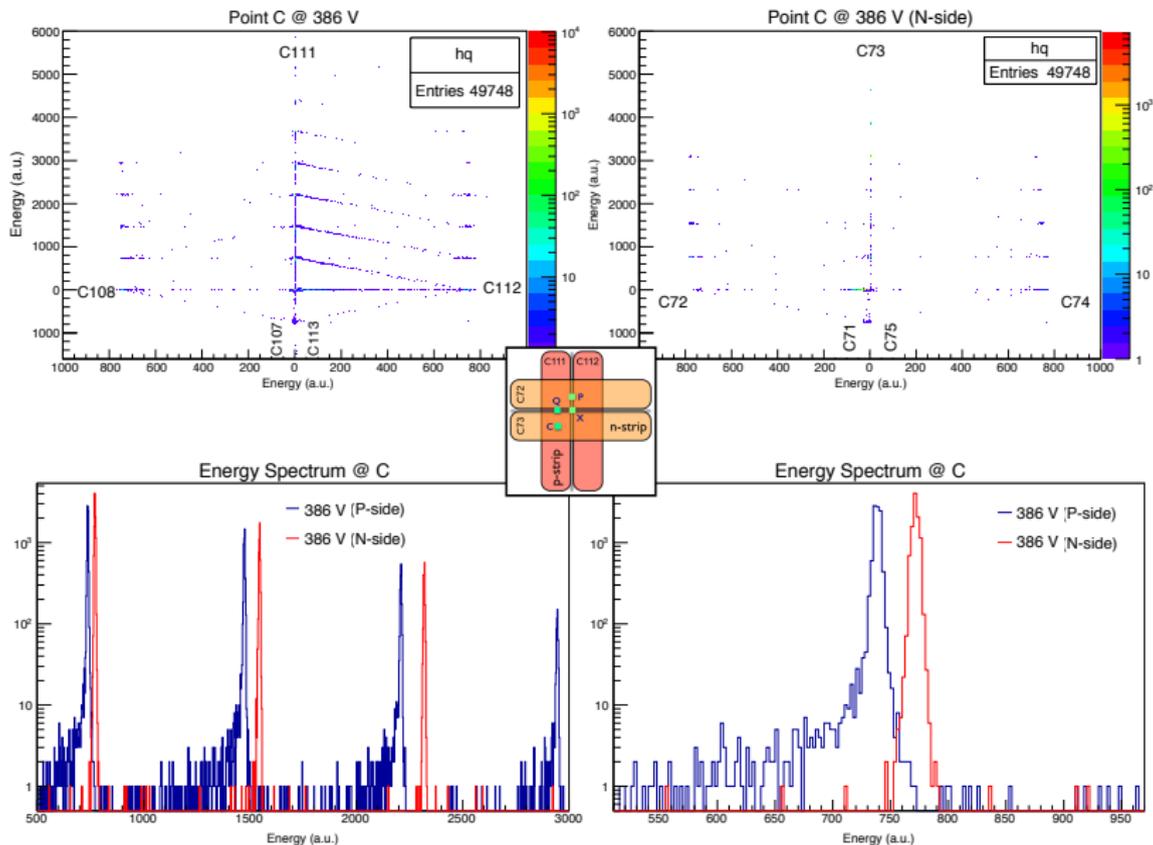
└ Under-depletion (317 V), P-strips (left) & N-strips (right) @ point C



Test with Microprobe @ LaBeC

└ Results, N-side injection

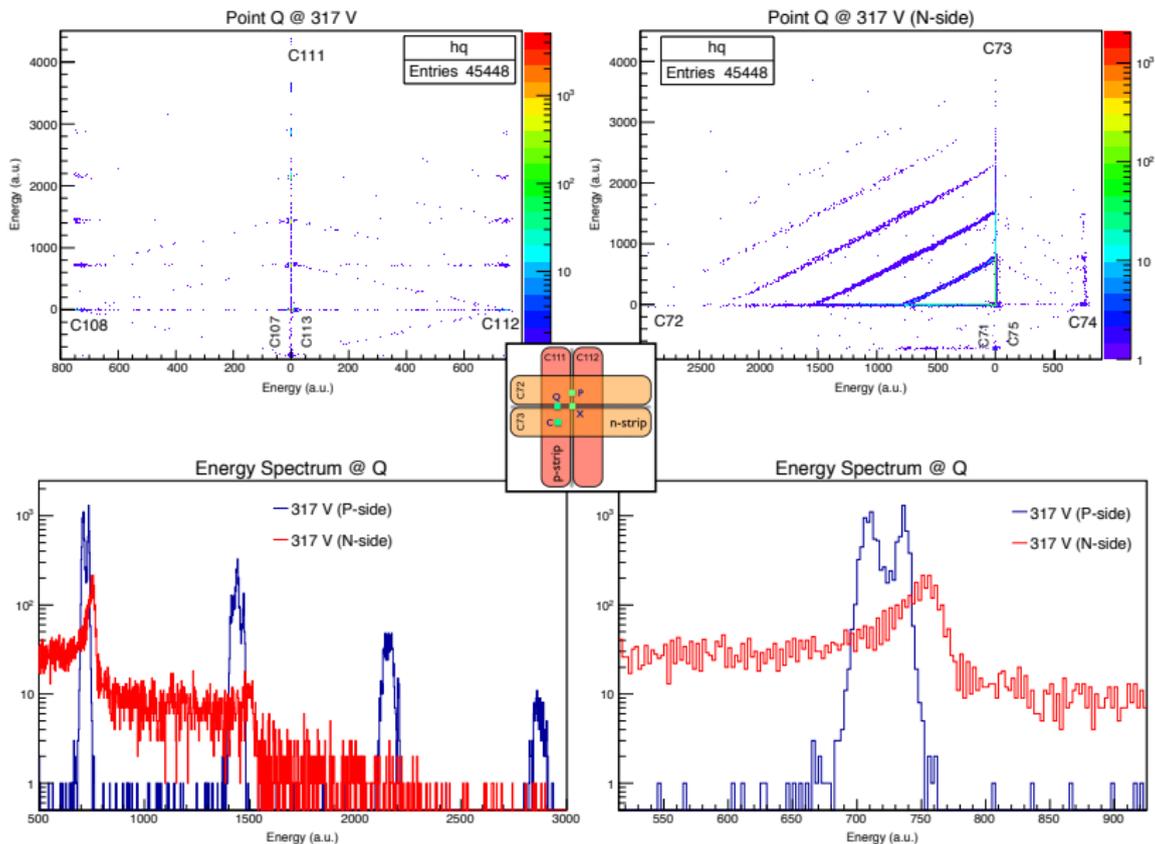
└ Over-depletion (386 V), P-strips (left) & N-strips (right) @ point C



Test with Microprobe @ LaBeC

└ Results, N-side injection

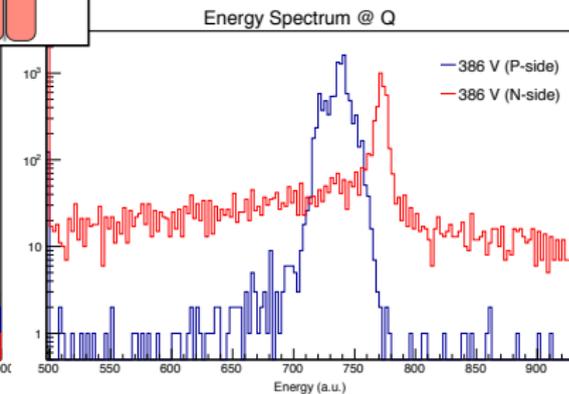
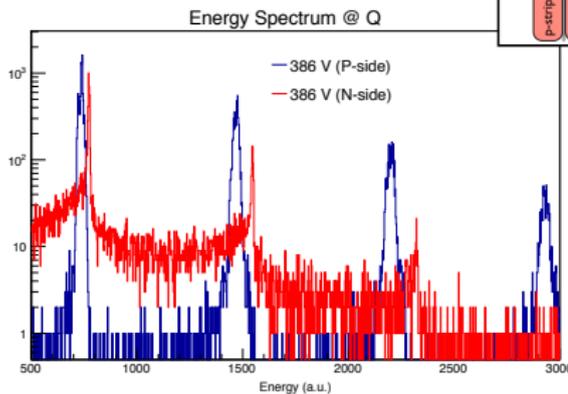
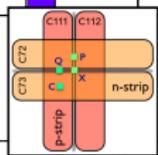
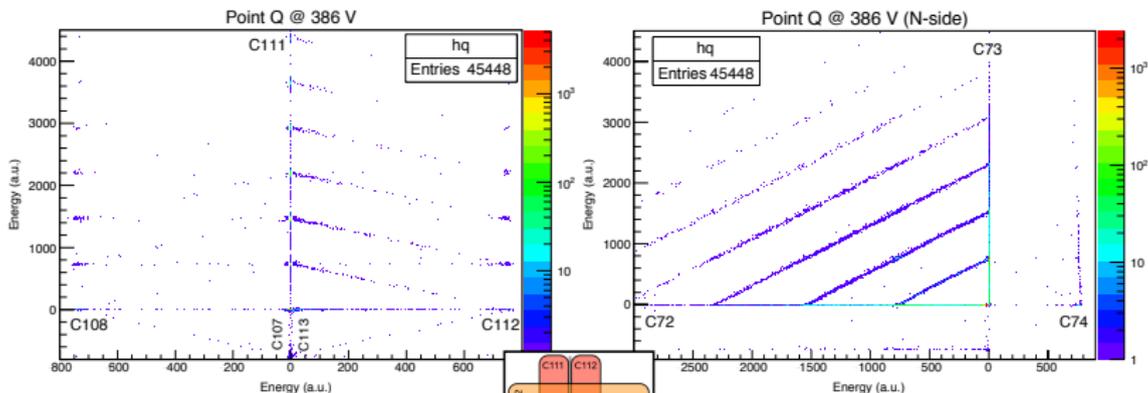
└ Under-depletion (317 V), P-strips (left) & N-strips (right) @ point Q



Test with Microprobe @ LaBeC

↳ Results, N-side injection

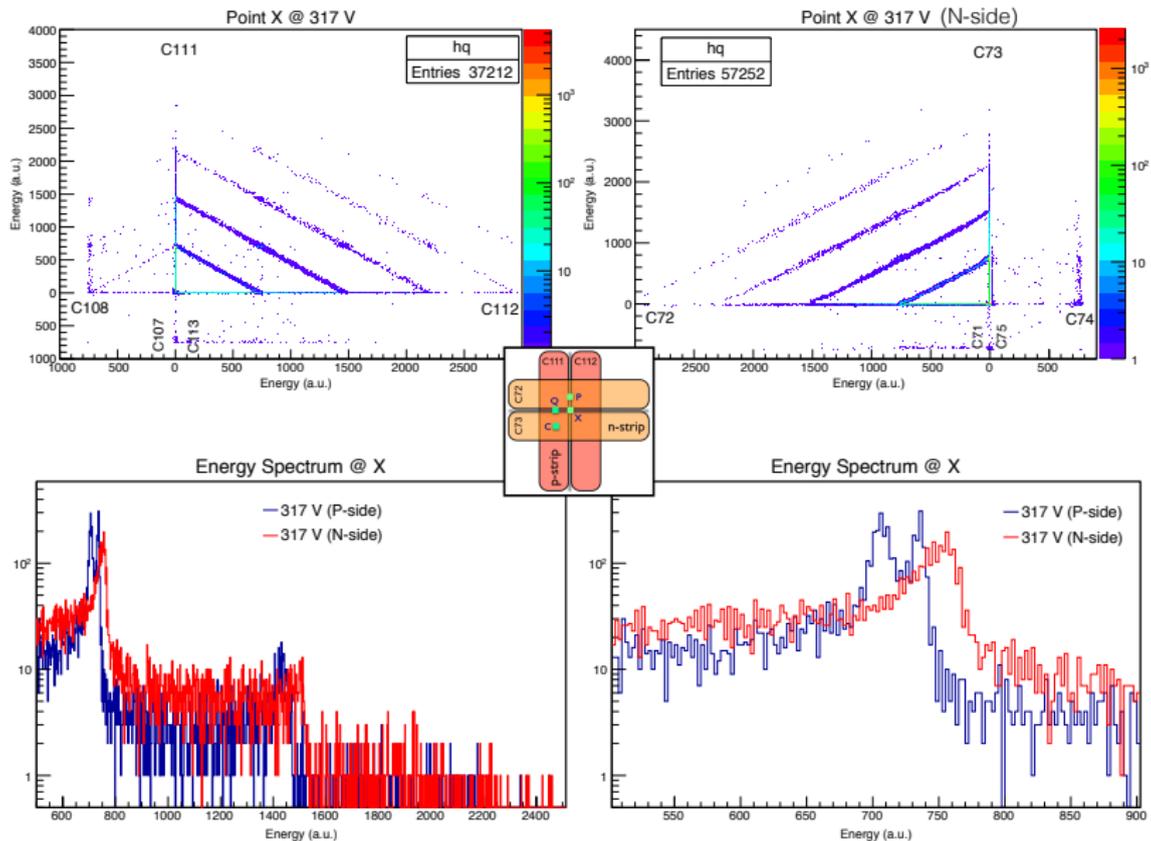
↳ Over-depletion (386 V), P-strips (left) & N-strips (right) @ point Q



Test with Microprobe @ LaBeC

Results, N-side injection

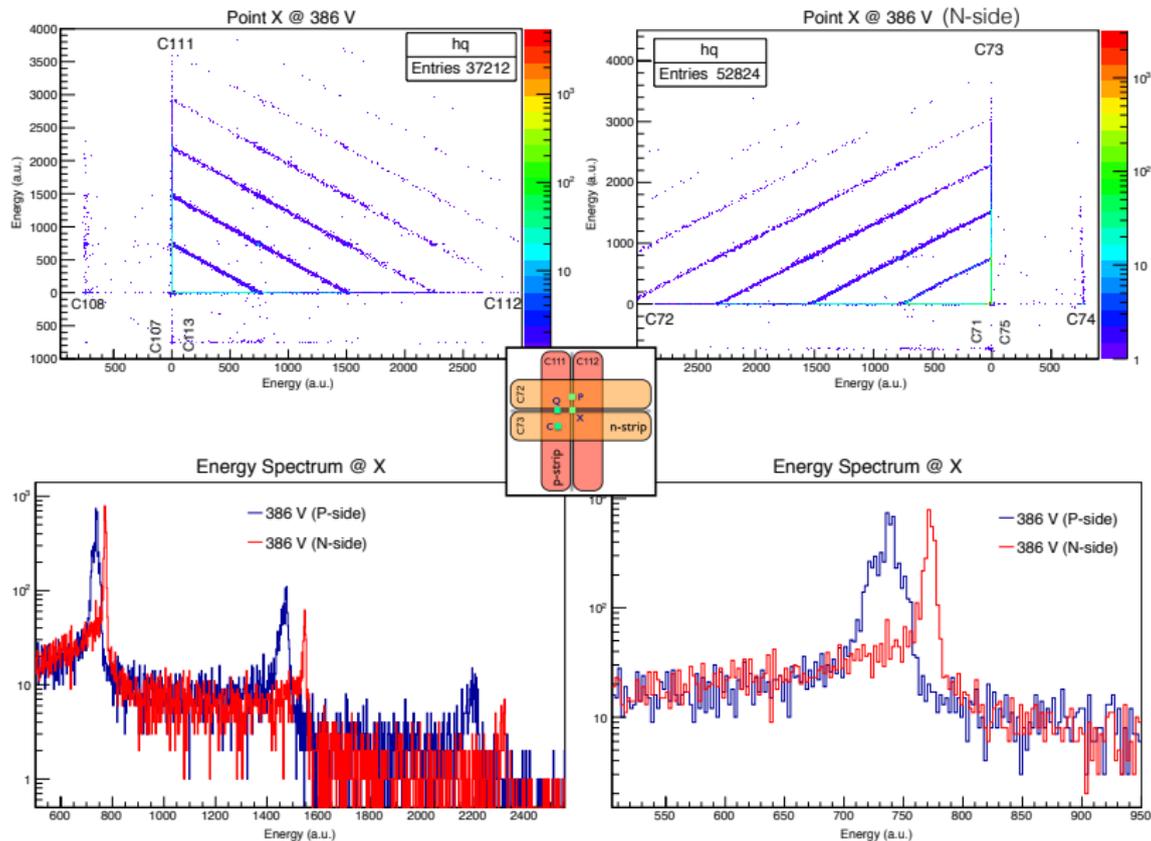
Under-depletion (317 V), P-strips (left) & N-strips (right) @ point X



Test with Microprobe @ LaBeC

Results, N-side injection

Over-depletion (386 V), P-strips (left) & N-strips (right) @ point X



Preliminary conclusions

- ▶ Good general performance of both detector + preamps.
- ▶ Capacitance with reasonable values, but not total leakage.
- ▶ Energy resolution down to 10 KeV for single proton particle.

Recommended future work

- ▶ Establish a protocol for detector characterisation.
- ▶ Study how to improve the Si manufacturing process to improve side asymmetry.
- ▶ Perform a test with beam size smaller than interstrip gap.